

IN THE CLAIMS

Please amend the claims as follows:

1-15. (Canceled)

16. (New) A process for producing a ceramic heater, comprising:
forming a resistance heating element on a surface of a ceramic substrate;
dividing the resistance heating element into plural sections;
measuring resistivities of said plural sections, respectively; and
trimming each of said plural sections according to a comparison between the
resistivities of said plural sections.
17. (New) The process for producing a ceramic heater according to claim 16,
wherein the trimming step includes trimming a side face of the resistance heating
element.
18. (New) The process for producing a ceramic heater according to claim 16,
wherein the trimming step includes trimming a surface of the resistance heating
element.
19. (New) The process for producing a ceramic heater according to claim 16,
wherein the forming step comprises,
providing a conductor containing paste layer on the surface of the ceramic substrate,
and
firing the ceramic substrate with the conductor containing paste layer.
20. (New) The process for producing a ceramic heater according to claim 16,
wherein said ceramic substrate comprises a nitride ceramic or a carbide ceramic.
21. (New) The process for producing a ceramic heater according to claim 16,
wherein said ceramic substrate has Ra of 10 μm or less according to JIS B0601.
22. (New) The process for producing a ceramic heater according to claim 16,

wherein the resistance heating element has a thickness of 1 to 30 μm .

23. (New) The process for producing a ceramic heater according to claim 16,

wherein the resistance heating element is divided into at least two circuits.

24. (New) The process for producing a ceramic heater according to claim 16,

wherein said ceramic substrate has a disc shape and has a diameter of 190 mm or more.

25. (New) The process for producing a ceramic heater according to claim 16,

wherein said ceramic substrate has a thickness of 1.5 to 5 mm.